ABSTRACT

A positive type photosensitive resin composition comprises a polyacrylate resin having, in the structure, at least a structural unit represented by the following general formula (1):

General formula (1)

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wherein X represents a hydroxyl group, an alkylol group having 2 to 4 carbon atoms, or a methylolamino group; R¹ and R² independently represents a hydrogen atom, or an alkyl group having 1 to 3 carbon atoms; R³ represents an alkyl group having 1 to 3 carbon atoms, an alkoxyl group having 1 to 3 carbon atoms, or an aralkyl group having an aryl group or alkyl group with 1 to 2 carbon atoms; n represents a positive integer; and m represents 0 or a positive integer, and a condensable crosslinker.